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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re the Application of

Hideki KOMATSUDA

Group Art Unit: 2851

Application No.: 09/697.639

Examiner: R Fuller

Filed: October 27, 2000

Docket No.: 105193.01

For: EXPOSURE APPARATUS AND METHOD OF FABRICATING A MICRO DEVI

USING THE EXPOSURE APPARATUS

INFORMATION DISCLOSURE STATEMENT

Director of the U.S. Patent and Trademark Office Washington, D.C. 20231

Sir:

Pursuant to 37 CFR §1.56, the attention of the Patent and Trademark Office is hereby directed to the reference(s) listed on the attached PTO-1449. Unless otherwise indicated herein, one copy of each reference is attached. It is respectfully requested that the information be expressly considered during the prosecution of this application, and that the reference(s) be made of record therein and appear among the "References Cited" on any patent to issue therefrom.

- This Information Disclosure Statement is being filed with a Request for Continued Examination. No certification or fee is required.
- 2. An English-language Abstract of the non-English language reference is attached hereto

Bespectfully submitted,

Mario A. Costantino Registration No. 33,565

MAC/ccs

Date: November 19, 2002

OLIFF & BERRIDGE, PLC P.O. Box 19928

Alexandria, Virginia 22320 Telephone: (703) 836-6400 DEPOSIT ACCOUNT USE AUTHORIZATION

Please grant any extension necessary for entry; Charge any fee due to our Deposit Account No. 15-0461